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81 Fottler Avenue, Lexington, MA 02420 (US). XIAN-FENG, Duan; 88 Beacon Street, Apt.#33, Somerville, MA 02143 (US).

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(74) Agents: FEATHERSTONE, Donald, J. et al.; Sterne, Kessler, Goldstein & Fox, P.L.L.C., 1100 New York Avenue, Washington, DC 20005 (US).

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(71) Applicant: NANOSYS, INC. [US/US]; 2625 Hanover Street, Palo Alto, CA 94304 (US).

(72) Inventors: STUMBO, David; 1561 6th Avenue, Belmont, CA 94002 (US). EMPEDOCLES, Stephen; 2507 Mardell Way, Mountain View, CA 94043 (US). CHUNMING, Niu;

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(54) Title: APPLICATIONS OF NANO-ENABLED LARGE AREA MACROELECTRONIC SUBSTRATES INCORPORATING NANOWIRES AND NANOWIRE COMPOSITES

